

Laser-Based Additive Nanomanufacturing: Rigid to Flexible Substrates

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Outline

- Printed Electronics
- Applications of Printed Electronics
- Laser-Based Additive Nanomanufacturing (ANM)
- Examples of ANM-Printed Devices
- Conclusion
- References
- Acknowledgment

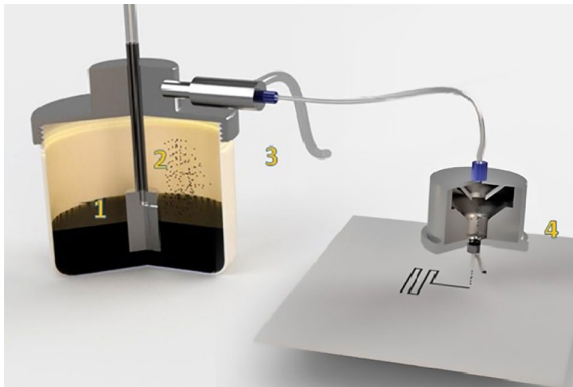
Printed Electronics

➤ Printed electronics:

- A set of printing methods used to create electrical devices on different substrates.

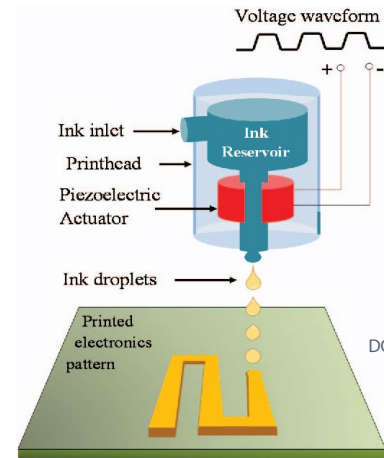
➤ Main printed electronic techniques are:

- **Aerosol jet and inkjet printing**, screen printing, gravure, offset lithography.



Aerosol jet printing

<https://www.led-professional.com/>

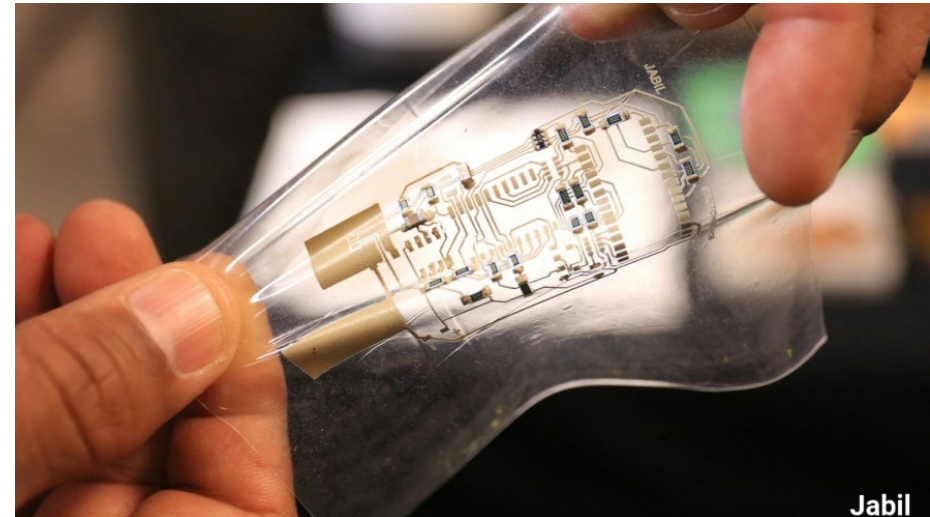
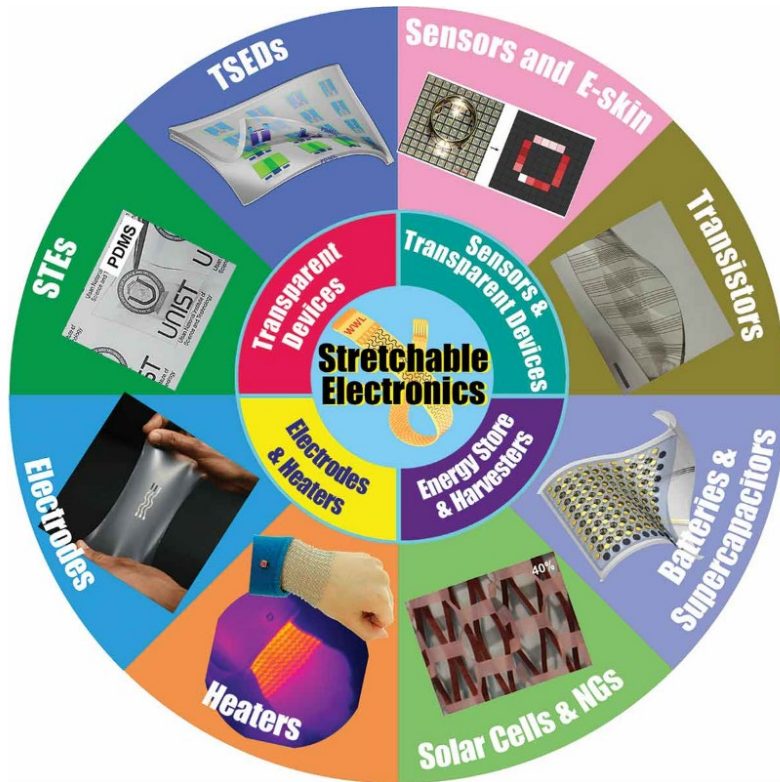


Inkjet printing

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- ❑ Aerosol jet and inkjet as a non-contact method have more design flexibility compared to other contact methods.

Applications of Printed Electronics



<https://www.semi.org/en/communities/flextech/what-are-flexible-electronics>



Advantages: product shape, weight, and durability

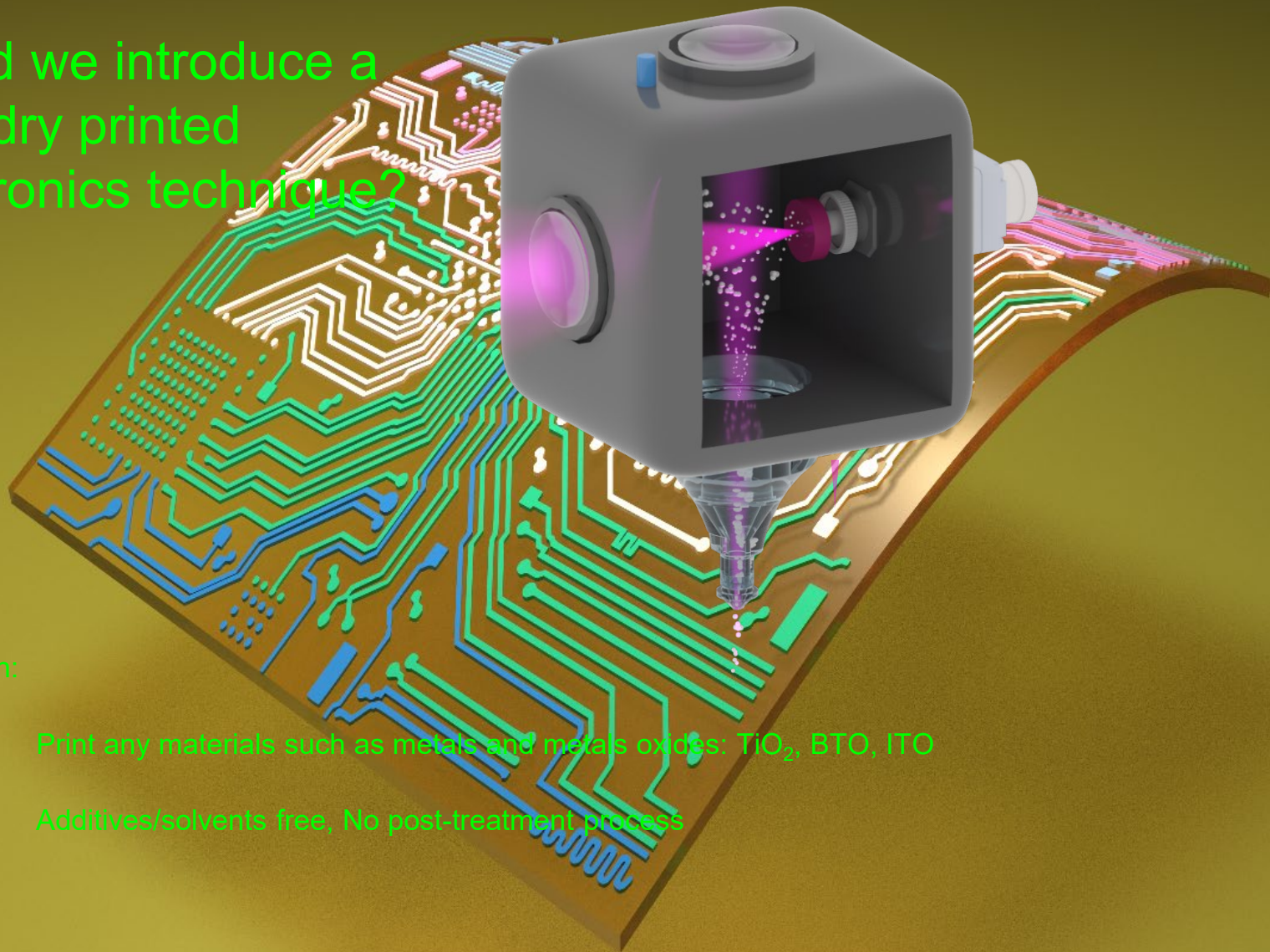
Flex circuits are printed on ultra-thin substrates, such as plastic, which impart them the foldable, rollable, and bendable characteristics without affecting the functionality.

Challenges of Inkjet and Aerosol Jet

- Solvents/additives are used in ink formulations: most inks are not pure liquids but have a very complex composition, containing multiple liquids with different material properties
 - As an example, for Ag ink: polyvindone+ethylene glycol+ AgNO_3
- Limited source of materials
- Additional post annealing step for removing additives/solvents
- Due to the liquid-nature of ink, it is not best option for paper-based printing
- Ink maintenance
 - Settle and need to shake



Could we introduce a
new dry printed
electronics technique?



Which can:

Print any materials such as metals and metals oxides: TiO_2 , BTO, ITO

Additives/solvents free, No post-treatment process

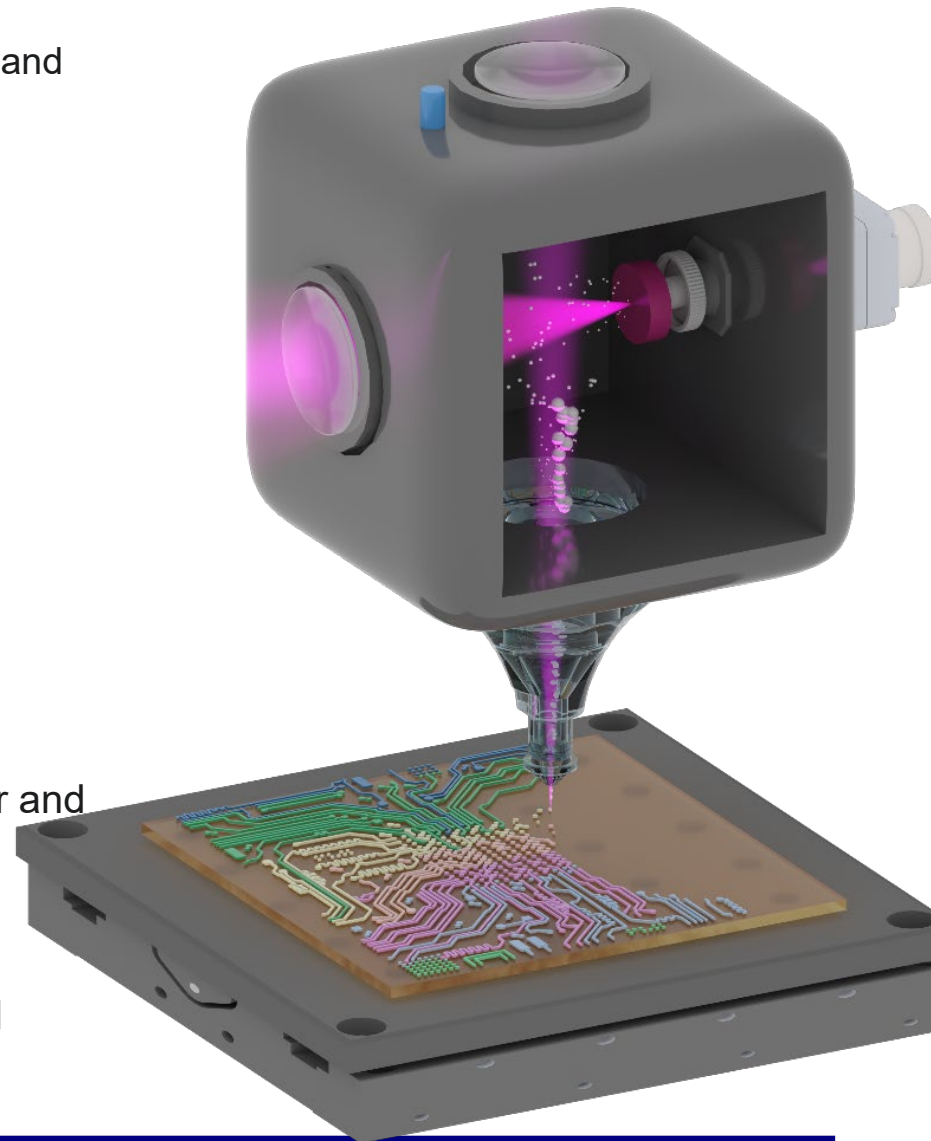
Laser-Based Additive Nanomanufacturing (ANM)

Process Steps:

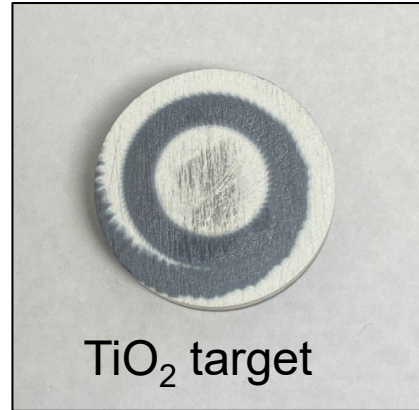
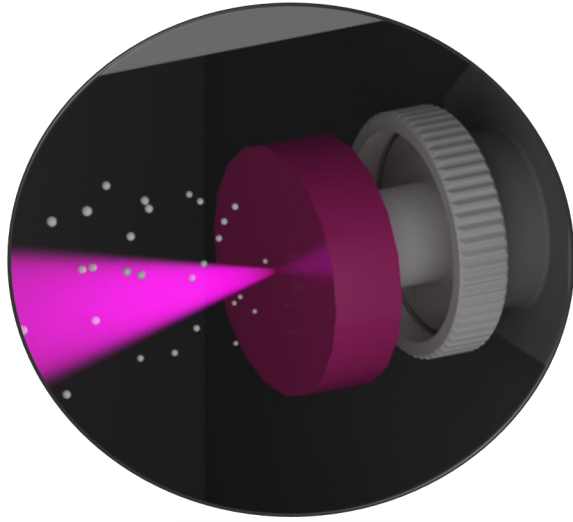
- Splitting pulsed excimer laser beam for sintering and ablation.
- Generating amorphous nanoparticles
- Delivery of nanoparticles
- Sintering of pure amorphous nanoparticles
- Scanning of stage

Key features of ANM system

- Generates dry and pure nanoparticles
- Compatible with rigid and flexible substrates
- Suitable for metals, semiconducting, insulator and metal oxides.
- Capable of patterning different shapes
- Non-contact process/ Room temperature and atmospheric pressure

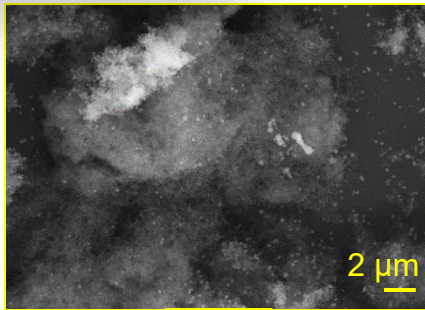


Ablated Nanoparticles-ANM process

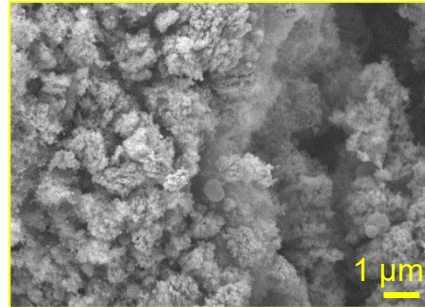


- Notes:
 - 248 nm excimer laser ablated the solid targets.
 - Nanoparticles generate during this interaction.

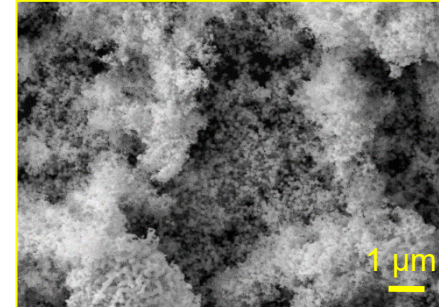
- Scanning Electronic Microscopy (SEM) images of produced nanoparticles:



TiO₂



ITO

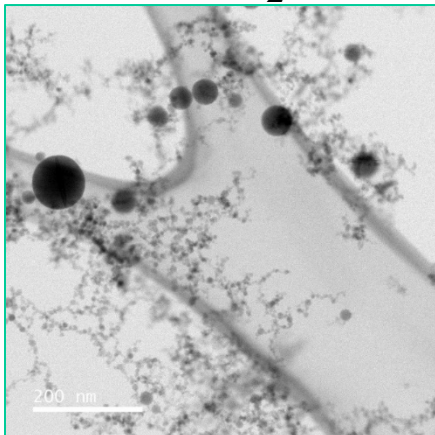


Ag

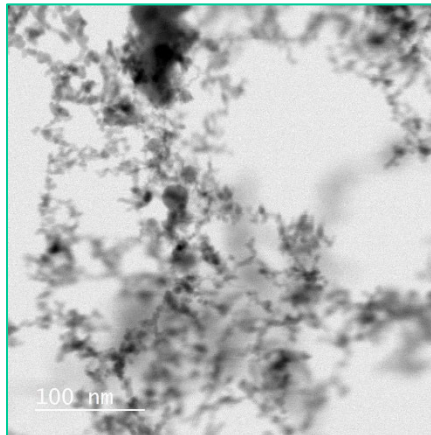
Ablated Nanoparticles- ANM process

Scanning Transmission Electron Microscopy (STEM)

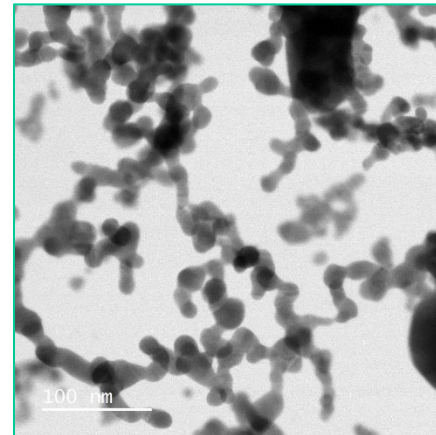
• TiO_2



• ITO



• Ag

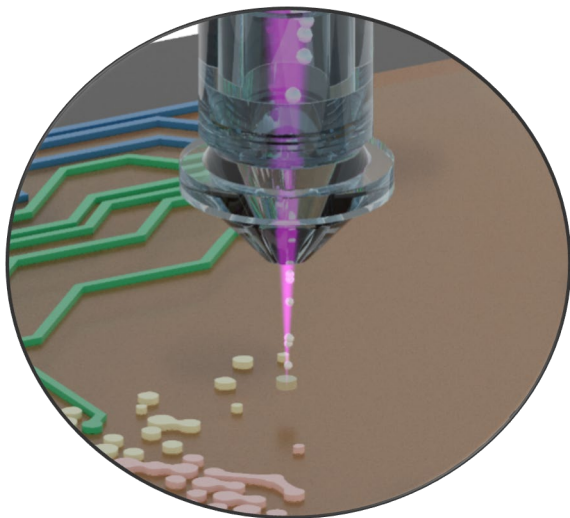


The nanoparticle size is ~3 to 10 nm.

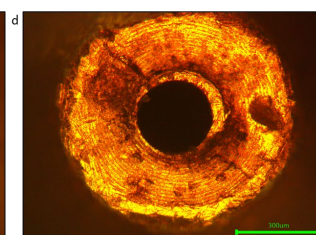
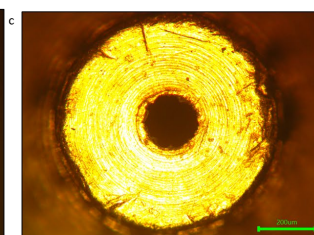
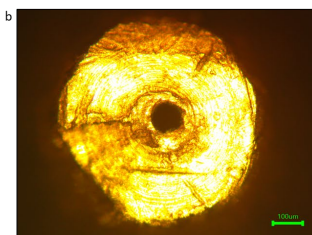
Comparison:

- Nanoparticles size in inkjet and aerosol jet printing ~ range of >10 nm, depending on the material.

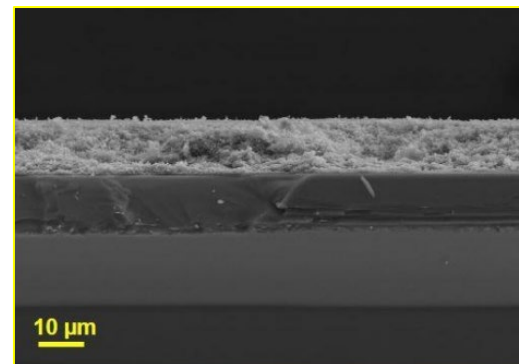
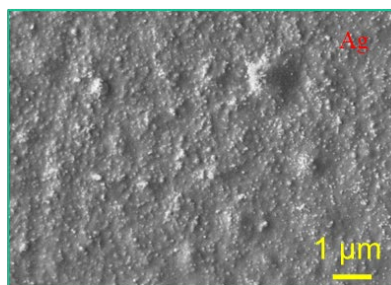
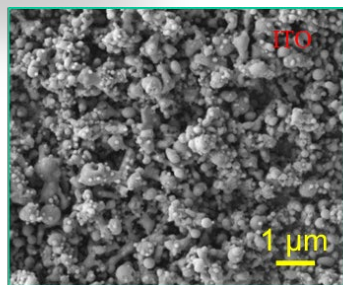
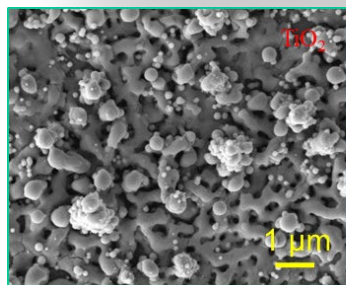
Laser Sintering and Crystallization of Nanoparticles



- Nanoparticles guided via carrier gas through the nozzle to the surface of the substrate.
- 248 nm excimer laser sinters and crystallizes the nanoparticles on the substrates.



- SEM images of sintered/crystallized nanoparticles:

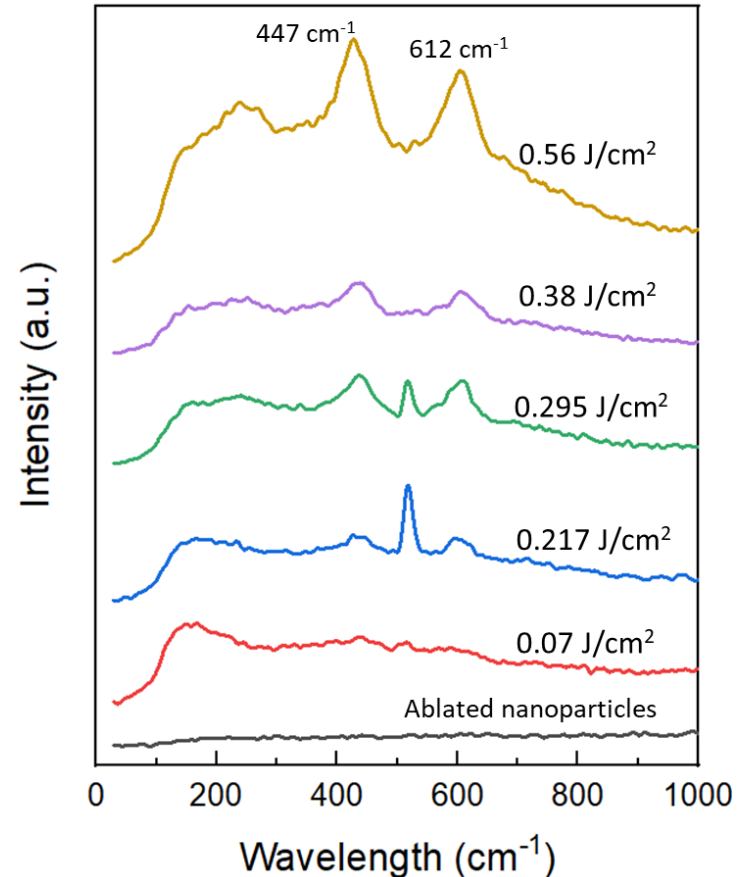


Cross-sectional SEM images showing the sintered ITO on SiO₂ substrate by the ANM process

Nanoparticles fused together during laser sintering/crystallization.

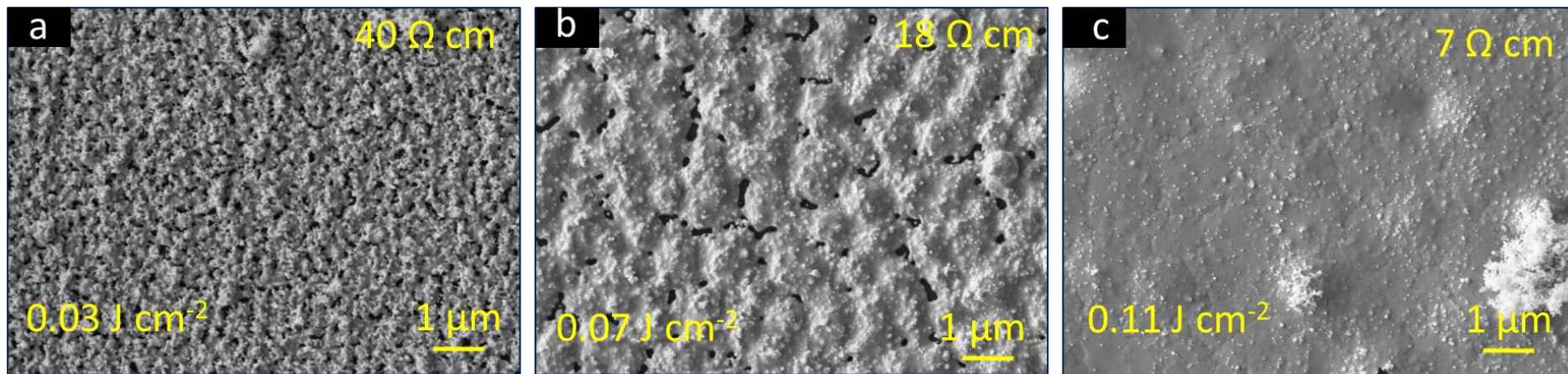
Raman Spectroscopy Study of TiO₂

- Effect of the laser beam energy on the crystallization of TiO₂ nanoparticles
 - In-situ generated nanoparticles
 - no peaks suggesting that the generated TiO₂ nanoparticles are primarily amorphous-TiO₂.
 - Using crystallization energy from 0.07 to 0.56 J cm⁻²,
 - Generated a-TiO₂ nanoparticles starts to sinter and crystallize (according to the appearance of new Raman peaks).
- The Raman lines at 447 cm⁻¹ and 612 cm⁻¹ are assigned to the Eg, A_{1g} modes of the rutile TiO₂ phase.
- Note:
 - Sintering and crystallization of anatase phase is possible by changing the carrier gas from Ar to O₂.

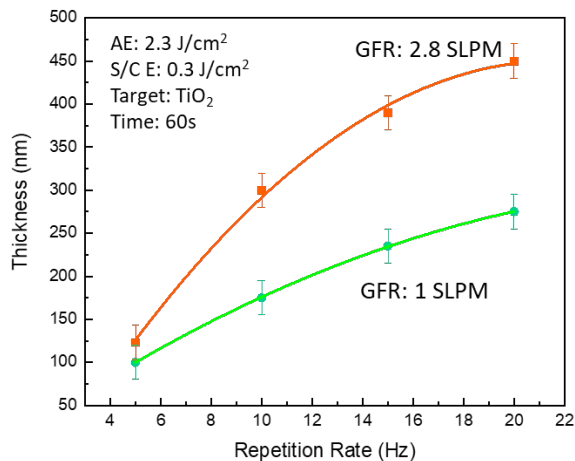
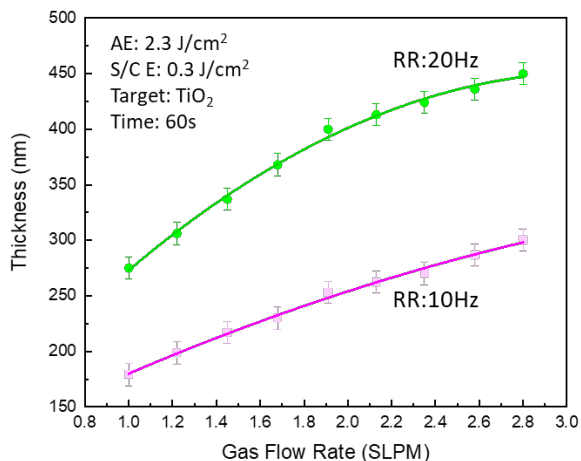


Morphological Evolution of Printed Ag Lines

- By increasing the sintering energy, the nanoparticles start to fuse together.
- The highest porosity was seen at the lower sintering energy ($\sim 0.03 \text{ J cm}^{-2}$)
- The lowest porosity was achieved at the higher laser sintering energy ($\sim 0.11 \text{ J cm}^{-2}$)

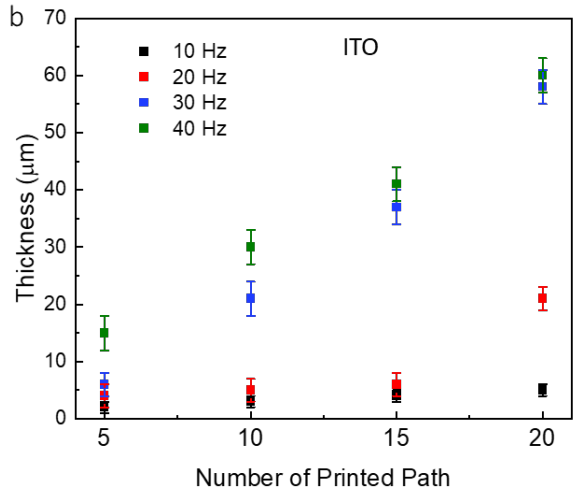
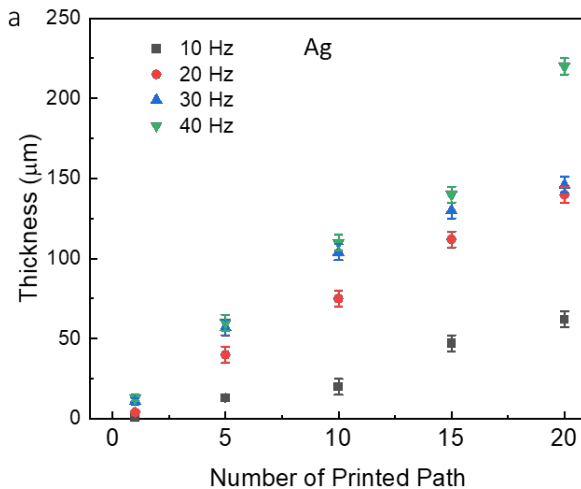


Thickness vs. ANM-parameters



- Increasing gas flow rate → increasing deposition thicknesses.
- Increasing repetition rate → increasing deposition thicknesses

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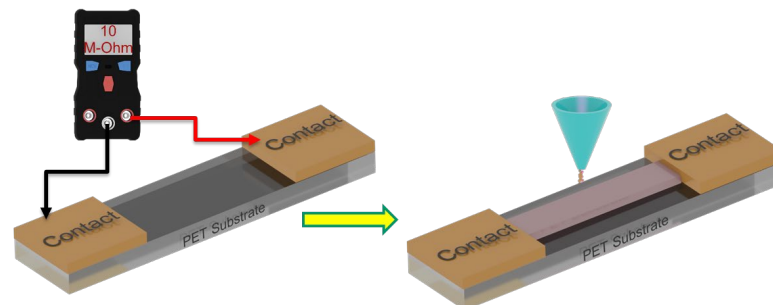
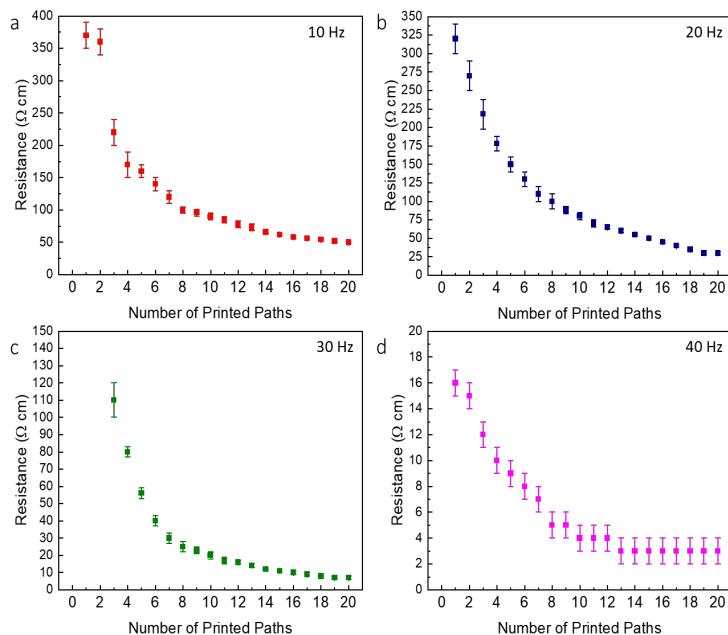


- With ANM technique, thickness is controllable.

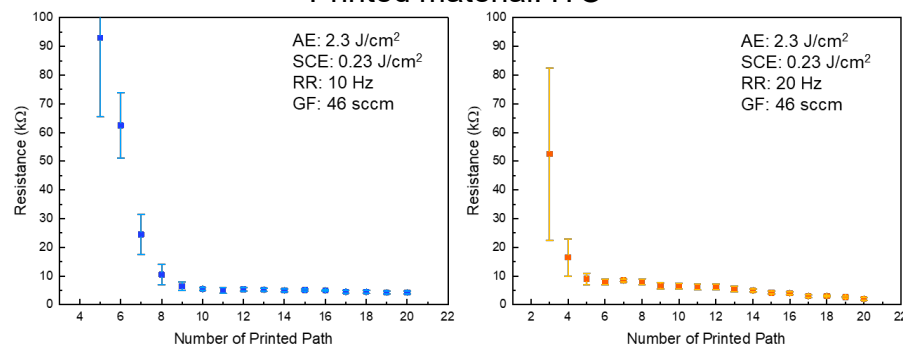
Resistance vs. Number of Printed Paths

Conductivity of printed ANM Ag and ITO as a function of different parameters:

Printed material: Ag

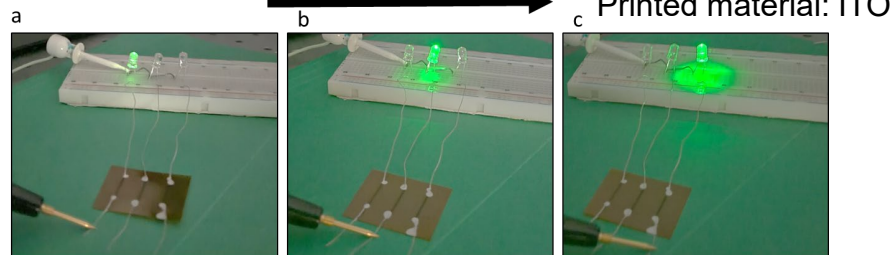


Printed material: ITO

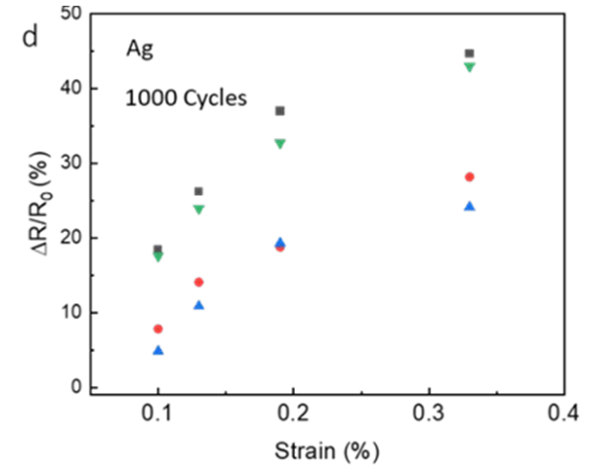
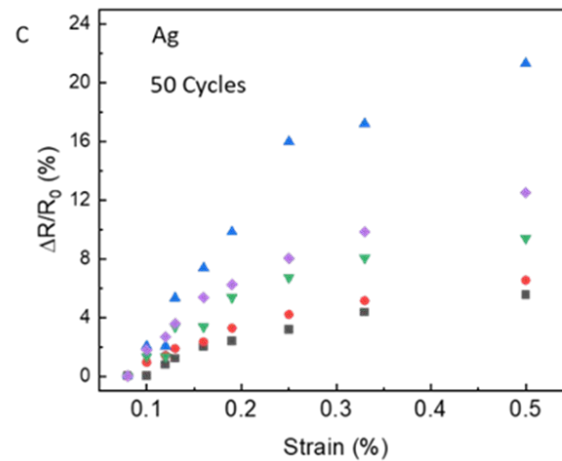
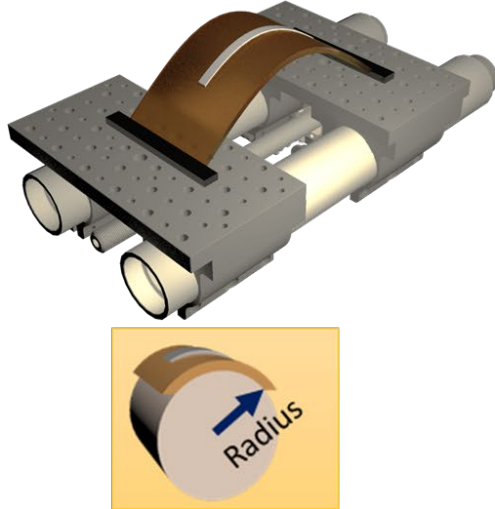


- The electrical resistivity has proportional relationship with number of printed paths.
- Increasing the repetition rate will result in increasing the line thickness and hence conductivity improvement.

Lower resistance
Higher LED intensity



Reliability Test on ANM-Printed Ag



$$\frac{\Delta R}{R_0} (\%) = \frac{R_s - R_0}{R_0} \times 100 \quad (1)$$

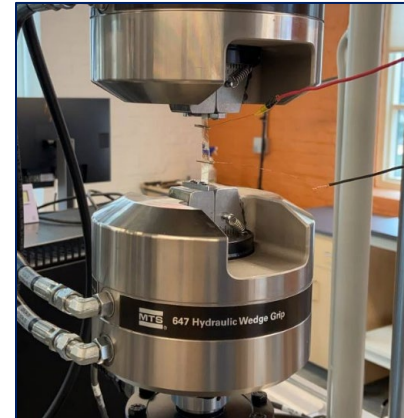
$$\text{Strain} (\%) = \frac{t_{\text{substrate}}}{2R_{\text{bend}}} \times 100 \quad (2)$$

R_0 , R_s , $t_{\text{substrate}}$, R_{bend} are initial resistance, under-stress resistance, substrate thickness, and bending radius, respectively.

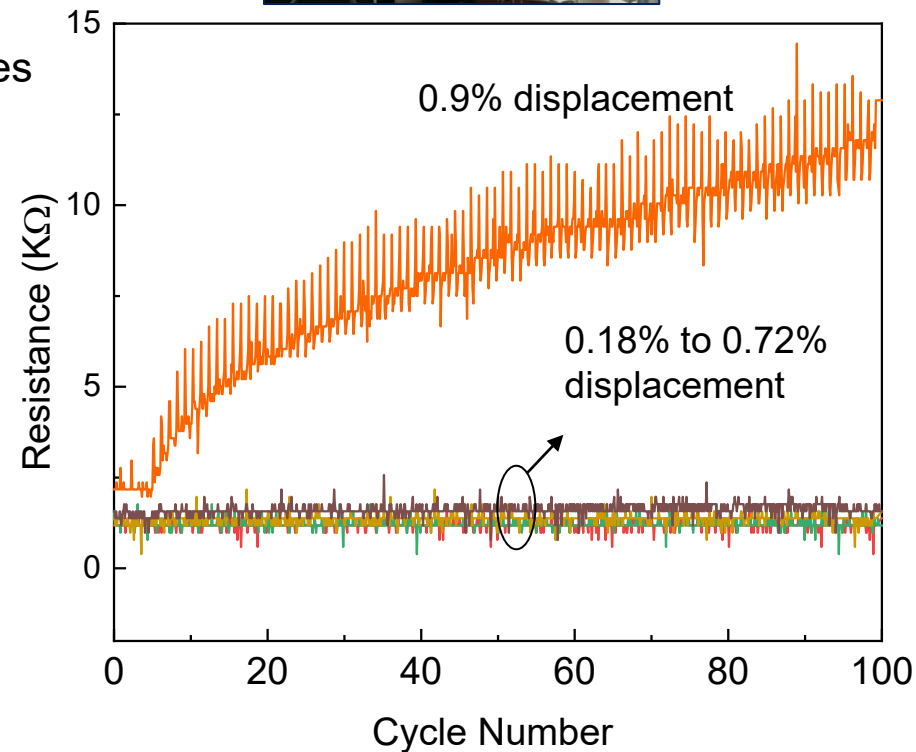
- The resistance increased more at higher bending strains (lower bending radius)
- According to the results:
 - tolerate a large strain with a slight increase in their electrical resistance.

Stretching Tests on ANM-Printed ITO

- Hydraulic fatigue machine used for stretching tests

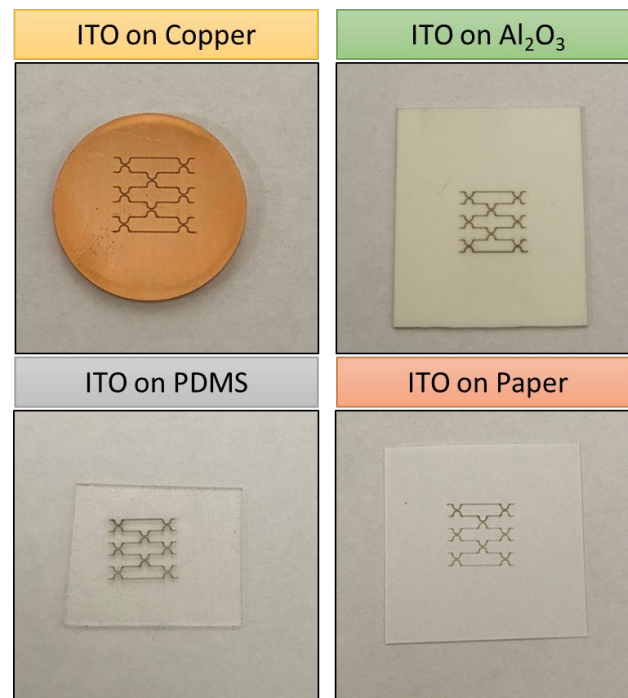
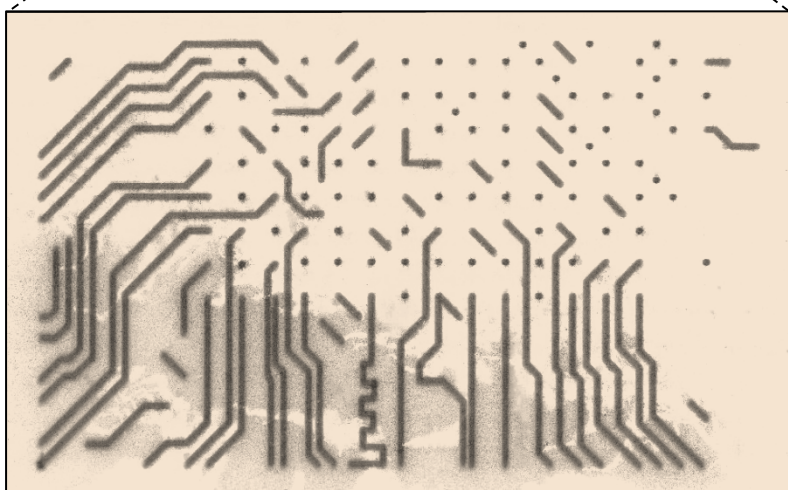
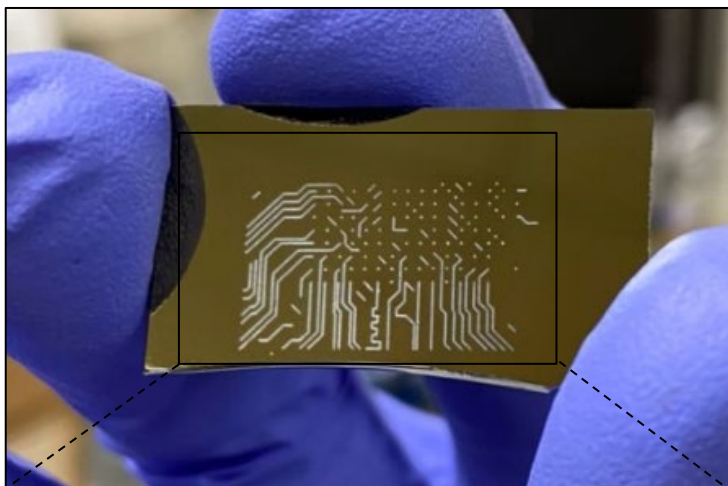


- ITO lines were printed onto the PET substrates (55 mm×5 mm×0.175 mm)
- Stretch from 0.18% to 0.9% displacement for 100 cycles
- Above 0.9% displacement, permanent substrate plastic deformation was observed, resulting in resistance overload



Applications

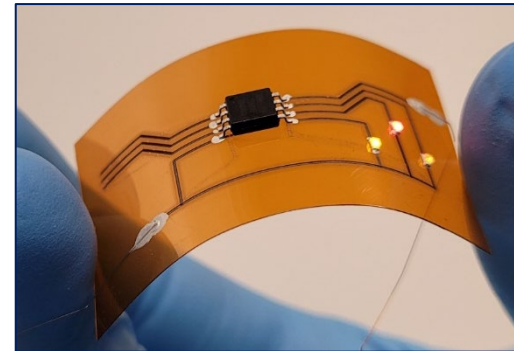
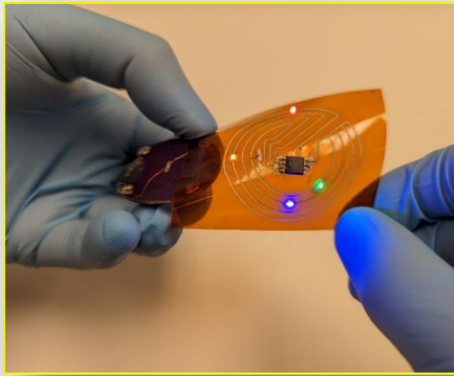
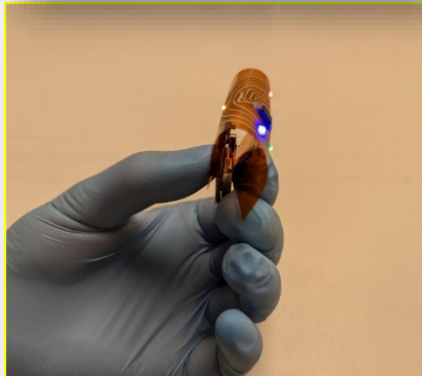
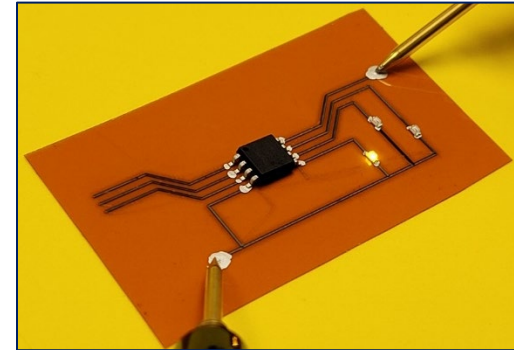
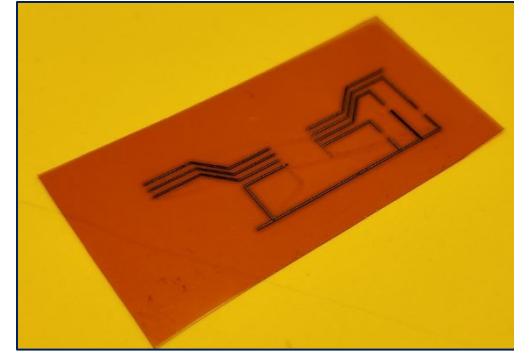
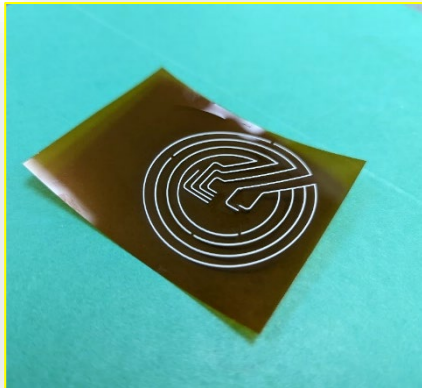
Additive Nanomanufacturing on Flexible and Rigid Substrate



- Printing on numerous substrates, including flexible substrates, paper, metals, glass, and ceramics.

Applications

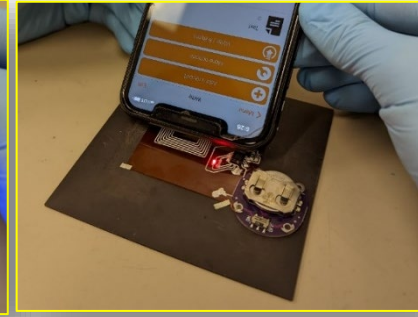
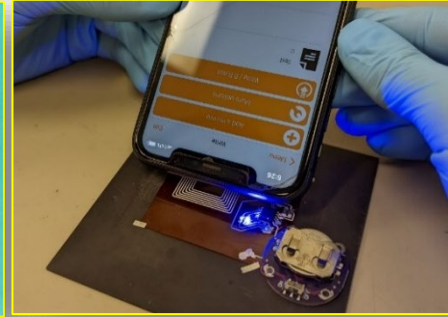
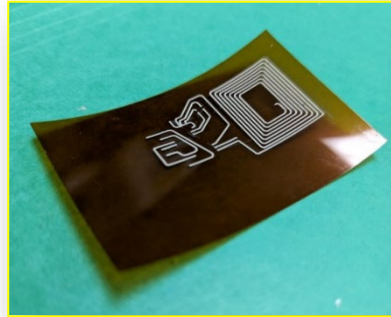
- Conductive electronics circuit and pattern of Ag printed by ANM process on polyimide substrate.
- Mounted SMD IC and LEDs on the circuit.



Applications

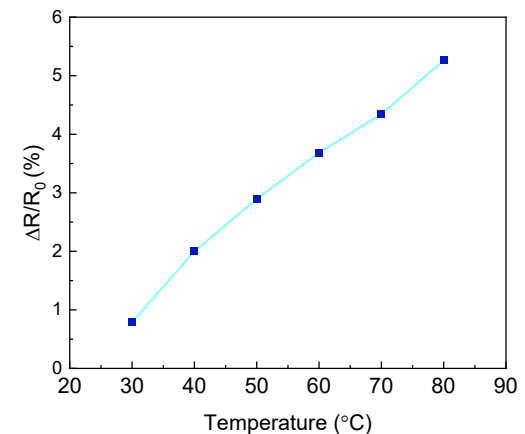
- Flexible Ag passive near field communication (NFC) tag for LED's controlling

- SMD LED, 2-3V
- ATtiny 85 IC programed with Arduino
- Silver paste



- Temperature sensor

- The sample on hotplate
- Temperature measurement range
- from 30 °C to 80 °C with 10 °C temperature increment.



The percentage of resistance change at different temperatures

Conclusion

- Inkjet and aerosol jet printing techniques have some disadvantages such as:
 - Solvents and additives used in ink
 - Limitation in materials selection

- We introduced a novel technique, Additive Nanomanufacturing (ANM) printing technique capable of:
 - Dry and solution-free printing (No additives or solvent)
 - Suitable for a wide range of materials including metals and metal-oxides
 - Compatible with variety range of rigid and flexible substrates

- Wide range of devices and applications can be printed by ANM-technique.

- Ahmadi, Zabihollah, et al. "Dry Printing and Additive Nanomanufacturing of Flexible Hybrid Electronics and Sensors." *Adv. Mater* (**2022**): 2102569.
- Ahmadi, Zabihollah, et al. "Additive Nanomanufacturing of Multifunctional Materials and Patterned Structures: A Novel Laser-Based Dry Printing Process." *Advanced Materials Technologies* 6.5 (**2021**): 2001260.
- Ahmadi, Zabihollah, et al. "Additive nanomanufacturing of functional materials and devices." *Laser 3D Manufacturing VIII*. Vol. 11677. International Society for Optics and Photonics, **2021**.

Acknowledgment

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- Alabama Micro/Nano Science and Technology Center (AMNSTC)



Q & A

Thanks for the attention
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